IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Confirmation No.: 2987

Takushi YOSHIDA, et. al. Date: August 23, 2007

Serial No.: 10/541,507 Group Art Unit: 1763

Filed: July 8, 2005 Examiner: Sylvia MacARTHUR

For: SUBSTRATE PROCESSING SYSTEM, SUBSTRATE PROCESSING

APPARATUS, PROGRAM AND RECORDING MEDIUM

VIA EFS-WEB

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

REPONSE TO RESTRICTION REQUIREMENT REMARKS/ARGUMENT

This Response is filed in reply to the Restriction Requirement dated July 30, 2007.

Applicant elects the invention of Group I, identified as claims 40-76, drawn to a substrate processing system.

Applicant reserves the right to file a divisional application directed to the subject matter covered in the non-elected claims.

Early and favorable consideration of the present application is earnestly solicited.

If this communication is filed after the statutory time period had elapsed and no separate Petition is enclosed, the Commissioner for Patents is petitioned, under 37 C.F.R. §1.136(a), to extend the time for filing a response to the outstanding Office Action by the number of months which will avoid abandonment under 37 C.F.R. §1.135. The fee under 37 C.F.R. § 1.17 should be charged to our Deposit Account No. 15-0700.

THIS CORRESPONDENCE IS BEING SUBMITTED ELECTRONICALLY THROUGH THE UNITED STATES PATENT AND TRADEMARK OFFICE EFS FILING SYSTEM ON AUGUST 23, 2007

Respectfully submitted,

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